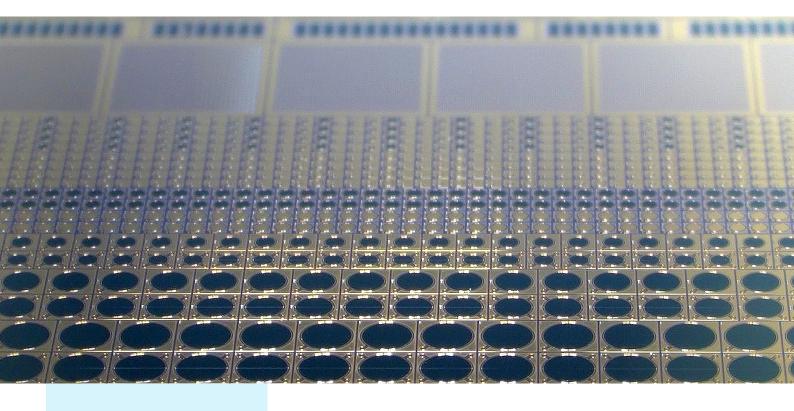
InGaAs AND EXTENDED InGaAs PHOTODIODES





AT A GLANCE

high quantum efficiency surface illuminated InGaAs photodiodes for sensing applications

Features

- low noise, high responsivity photodiodes
- single diode, segmented diodes or array configuration
- backside or front side illumination
- lens integration for back side illuminated photodiode (optional)
- flip-chip or wire bonding
- zero bias opperation possible

Applications

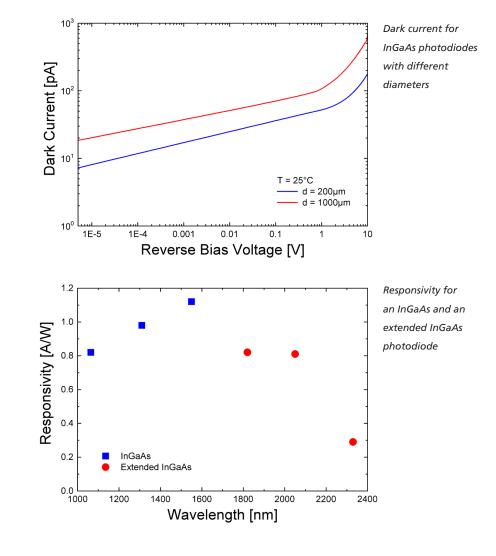
- . . .
- SWIR sensing and imaging

Technical Background

Surface-illuminated photodiodes with low noise and high quantum efficiency are key components for short wavelength infrared (SWIR) sensing applications. The standard InGaAs photodiodes operate at a wavelength of 820 nm up to 1650 nm. For the extended InGaAs devices, the upper absorption wavelength can be shifted up to 2500 nm.

The photodiode chips are based on mature InP technology and are fabricated at the wafer process line of HHI, having Telcordia and space-qualified processes. Due to the ability of customising the photodiode chips, costumers obtain the optimal performance for their application.





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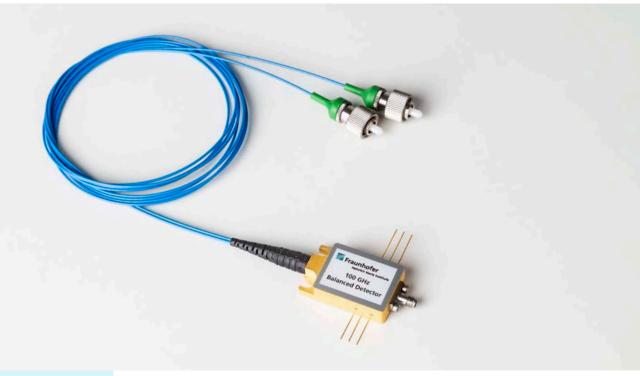
Customization

- optical aperture up to a few mm-diameter
- quantum efficiency up to 99%
- planar or mesa type photodiodes
- single photodiode, segmented photodiode or array configuration
- segmented photodiodes and arrays with common or isolated cathode

- backside or front side illumination
- lens integration for backside illuminated photodiode
- flip-chip or wire bonding
- customized pitches and pad configurations
- APD and SPAD photodiode types also available

100 GHz BALANCED PHOTODETECTOR MODULE





AT A GLANCE

high-speed balanced photodetector module for > 1T/bs coherent telecom applications

Features

- up to 100 GHz 3 dB-bandwidth
- detection of 128 GBaud x-QAM signals with optical 90° hybrid
- integrated bias network
- low bias operation
- 1 mm RF connector

Applications

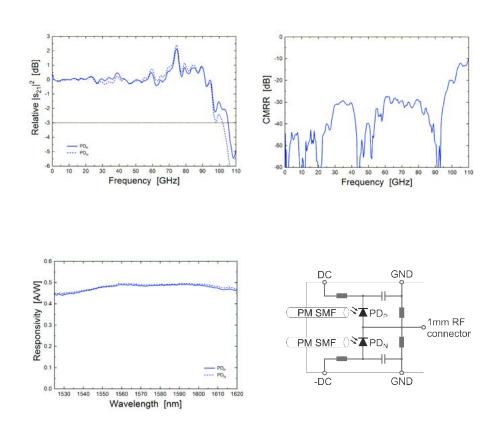
- telecommunication
- coherent test- & measurement systems
- microwave photonics

Technical Background

High-speed balanced photodetector modules are of interest for the development of next-generation telecom coherent optical communication links. Since these R&D links are always a step ahead in terms of symbol rates, photodetector modules with a RF bandwidth beyond state-of-the-art are needed at the receiver side. In combination with a 90° optical hybrid, the balanced photodetectors provide the functionality of a coherent receiver for detecting dual-polarization higher order QAM signals.

The photodetector chips inside the modules are based on mature InP technology and are fabricated at the wafer process line of HHI, offering Telcordia and space-qualified processes. The chips are packaged at HHI facilities.





- 3 dB-bandwidth: up to 100 GHz
- wavelength: 1480 nm 1620 nm
- low dark current: < 100 nA @ 3V
- bias voltage: +2 V and -2 V
- 1mm female RF connector
- RF output matched to 50 Ω
- optical input: FC/APC PM SMF fibre

or

SC/APC PM SMF fibre

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100 GHz PHOTODETECTOR MODULE





AT A GLANCE

high-speed photodetector module for > 1 T/bs PAM datacom, telecom and microwave photonics applications

Features

- up to 100 GHz 3 dB-bandwidth
- detection of 128 GBaud amplitude modulated signals
- operation in O-band and C+L-band
- integrated bias network
- low bias operation
- 1 mm RF connector

Applications

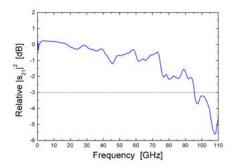
- datacommunication
- telecommunication
- test- & measurement systems
- microwave photonics

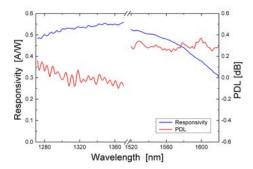
Technical Background

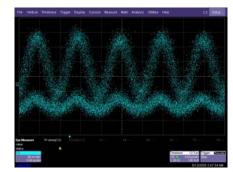
High-speed photodetector modules are of interest for the development of nextgeneration optical communication links in datacom and telecom. Since these R&D links are always a step ahead in terms of symbol rates, photodetector modules with a RF bandwidth beyond state-of-the-art are needed at the receiver side. Furthermore, the highspeed performance of the photodetector modules makes them applicable to microwave photonics.

The photodetector chips inside the modules are based on mature InP technology and are fabricated at the wafer process line of HHI, offering Telcordia and space-qualified processes. The chips are packaged at HHI facilities.

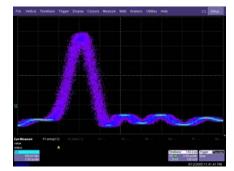








107 GB/s PRBS sequence



2.4 ps FWHM input pulse

- 3 dB-bandwidth: up to 100 GHz
- C+L-band option wavelength: 1480 nm - 1620 nm responsivity: 0.5 A/W @ 1550 nm
- O-band & C+L-band option wavelength: 1270 nm - 1620 nm responsivity: 0.45 A/W @ 1550 nm 0.5 A/W @ 1310 nm
- PDL: < 0.5 dB
- optical input power: up to +15 dBm
- dark current: < 100 nA @ 3V
- bias voltage: +2 V
- 1 mm female RF connector
- RF output matched to 50Ω
- optical input: FC/APC SMF fibre

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145 GHz PHOTODETECTOR MODULE





AT A GLANCE

high-speed photodetector module for > 1 T/bs PAM datacom, telecom and microwave photonics applications

Features

- up to 145 GHz 3 dB-bandwidth
- detection of 200 GBaud amplitude modulated signals
- operation in C- and L-band
- integrated bias network
- low bias operation
- 0.8 mm RF connector

Applications

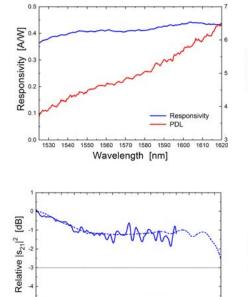
- datacommunication
- telecommunication
- test- & measurement systems
- microwave photonics

Technical Background

High-speed photodetector modules are of interest for the development of nextgeneration optical communication links in datacom and telecom. Since these R&D links are always a step ahead in terms of symbol rates, photodetector modules with a RF bandwidth beyond state-of-the-art are needed at the receiver side. Furthermore, the highspeed performance of the photodetector modules makes them applicable in microwave photonics.

The photodetector chips inside the modules are based on mature InP technology and are fabricated at the wafer process line of HHI, having Telcordia and space-qualified processes. The modules are also packaged at Fraunhofer HHI facilities.



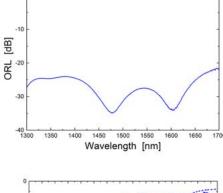


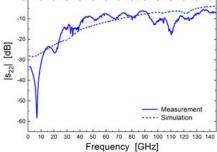
Measurem

Simulation

....

50 60 70 80 90 100 110 120 130 140 Frequency [GHz]





Technical Specifications

-6

- wavelength: 1480 nm 1620 nm
- 3 dB-bandwidth: up to 145 GHz
- low dark current: < 100 nA @ 3V
- bias voltage: +2 V
- 0.8 mm female RF connector
- RF output matched to 50Ω
- optical input: FC/APC PM SMF fibre

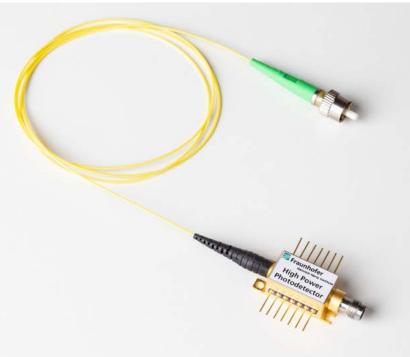
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HIGH-POWER PHOTODETECTOR MODULE





AT A GLANCE

High-speed photodetector module for microwave photonics applications

Features

- up to 65 GHz 3 dB-bandwidth
- single or balanced configuration
- operation in C- and L-band
- integrated bias network
- 1.85 mm RF connector

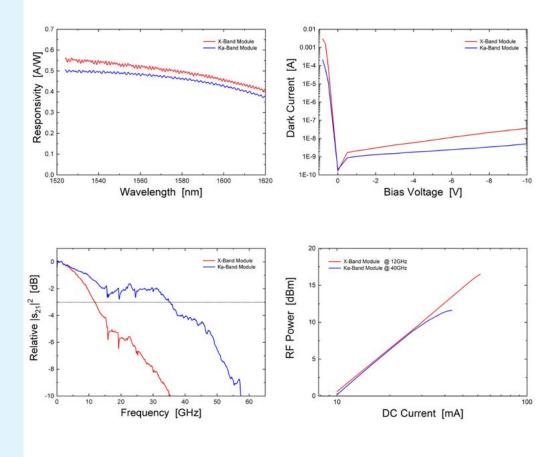
Applications

- radio-over-fibre
- phased array antennas
- precision frequency generation
- photonic channelizer

Technical Background

High-power photodetector modules are of interest for down-converting optically generated signals in the field of microwave photonics. The photodetector chips inside the modules are based on mature InP technology and are fabricated at the wafer process line of HHI, having Telcordia and space-qualified processes. The modules are also packaged at HHI facilities.





- _____
- wavelength: 1480 nm 1620 nm
- 3 dB-bandwidth: up to 65 GHz
- low dark current: < 100 nA @ 3V
- 1.85 mm female RF connector
- optical input: FC/APC SMF fibre

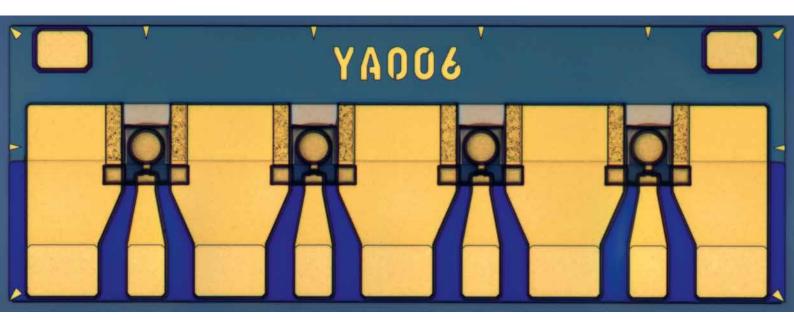
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56 GBaud, 32 GBaud AND 28 GBaud SURFACE ILLUMINATED PHOTODIODES





AT A GLANCE

high-speed surface illuminated InGaAs photodiodes for datacom, telecom and sensing applications

Features

- up to 60 GHz 3 dB-bandwidth
- back side or top side illumination
- single diode or array configuration
- lens integration for back side
 illuminated photodiode (optional)
- integrated bias-T (optional)
- flip chip or wire bonding
- IEEE P802.3 bs compliant

Applications

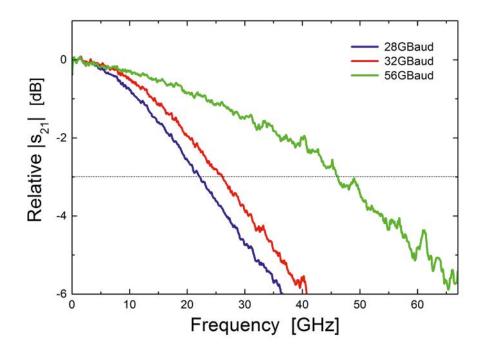
- datacommunication
- telecommunication
- sensing

Technical Background

High-speed surface-illuminated photodiodes are key components for hybrid-integrated photodetectors in datacom and telecom transceivers. The photodiodes operate at a wavelength of 1310 nm for intra-datacenter links or 1550 nm for inter-datacenter and long-haul optical communication links.

The photodiode chips are based on mature InP technology and are fabricated at the wafer process line of HHI, offering-Telcordia and space-qualified processes. Due to the ability of customising the photodiode chips, costumers get the optimal performance for their application.





- wavelength: 1060 nm 1700 nm
- responsivity: 28 GBaud: 0.95 A/W @ 1310 nm 32 GBaud: 0.75 A/W @ 1550 nm 56 GBaud: 0.7 A/W @ 1310 nm 0.55 A/W @ 1550 nm
- low dark current: < 10 nA @ 5V
- IEEE P802.3 bs compliant

Customisation

- 3 dB-bandwidth up to 60 GHz
- customised responsivity-bandwidth trade-off
- back side or top side illumination
- single diode or array configuration
- integrated bias-T
- lens integration for back side illuminated photodiode
- flip chip or wire bonding
- customised pitches and pad configurations

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